

Title (en)
MANUFACTURING METHOD FOR AN ELECTRODE FOR ELECTROCHEMISTRY

Title (de)
HERSTELLUNGSVERFAHREN FÜR EINE ELEKTRODE FÜR ELEKTROCHEMIE

Title (fr)
PROCÉDÉ DE FABRICATION D'UN ÉLECTRODE POUR ÉLECTROCHIMIE

Publication
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Application
EP 12805786 A 20121101

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Abstract (en)
[origin: WO2013069711A1] The present invention provides an electrode for electrochemistry with a high quality, in which the surface area of the polycrystalline conductive diamond layer is increased and the crystal plane is controlled. In addition, when the catalyst layer of electrode substance is coated on the polycrystalline conductive diamond layer, adherence between the two layers is increased to provide an electrode for electrochemistry with a high durability. The polycrystalline conductive diamond layer is held under an atmosphere of carbon dioxide at a temperature 400 degrees Celsius or higher but 1000 degrees Celsius or lower to make the polycrystalline conductive diamond layer porous and make a specific crystal plane to remain and be formed.

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